





Florida Solar Energy Center • November 1-4, 2005

Multi-scale Surface Plate Fabrication for **Next Generation Fuel Cells**

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Planned Completion = August 2 2005









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Research Goals and Objectives

- combine new and existing manufacturing technologies to improve PEM fuel cell collection plate performance
- low-cost, agile feature production from the nanometer to millimeter scales using
 - micro-molding in bulk metallic glass (Vitreloy-1)
 - high-speed machining
 - photolithography
- demonstrate channel production with varying geometries and validate fidelity







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Relevance to Current State-of-the-Art

- increased power and efficiency gains possible through improved flow fields and current collection capabilities of PEM fuel cells
- provide mechanism to produce arbitrary channel geometries quickly with low capital investment
- multiple length scales important for miniaturized collection plates
- competing technologies: LIGA, FIB, micro-EDM, excimer/femto-second laser – micro-molding offers 3D metallic component production without high energy x-ray source







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Technology	Minimum size/tolerance	Positional tolerance	Material removal rate	Materials
Focused ion beam/2D and 3D	200 nm/20 nm	100 nm	0.5 μm³/s	Any
Excimer laser/2D or 3D	6 μm/<1 μm	<1 µm	40x10 ³ μm ³ /s	Polymers, ceramics, metals
Femto-second laser/2D or 3D	1 μm/<1 μm	<1 µm	>10x10³ µm³/s	Any
Micro EDM (sinker or wire)/2D or 3D	25 μm/3 μm	3 µm	25x10 ⁶ μm ³ /s	Conductive materials
LIGA/2D	<1 μm/0.02 μm to 0.5 μm	<1 µm	N/A	Electroformable Cu, Ni, permalloy

Relevance to NASA

- activities are synergistic with other ongoing fuel cell research efforts (e.g., thermal management, computational fluid dynamics)
- other applications may arise once capabilities are known







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Budget, Schedule and Deliverables

Budget: \$70,000

Milestones

- Q1: Modify MTS dual column load frame; control using LabView
- Q2: Provide temperature control for metallic glass micro-molding of various features
- Q3: Reproduce micrometer scale features with aspect ratios >1
- Q4: Produce plate for tests by Dr. Klausner

Deliverables

- Q1: Demonstrate force and position control of MTS load frame
- Q2: Ramp and hold temperature to >400 deg C for micro-molding experiments
- Q3: Obtain silicon wafers with combinatorial features, reproduce, and measure surfaces
- Q4: Establish micro-molding capability







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Anticipated Technology End Use

- initially convenient platform to evaluate models
- future friendly to shop floor implementation (low molding temperatures, clean room not required)
- other application domains
 - 1. optics flexible mirrors/arrays, diffraction gratings, waveguides
 - 2. medical micro-textured scaffolds for tissue engineering
 - 3. thermal systems micro-scale heat exchangers
 - 4. fluidic systems 3D channel patterns, turbines, valves
 - 5. electronics high-Q solid oscillators, final step in CMOS
 - 6. mechanical systems MEMS packaging, monolithic micro-scale pumps, compressors, fuel injectors

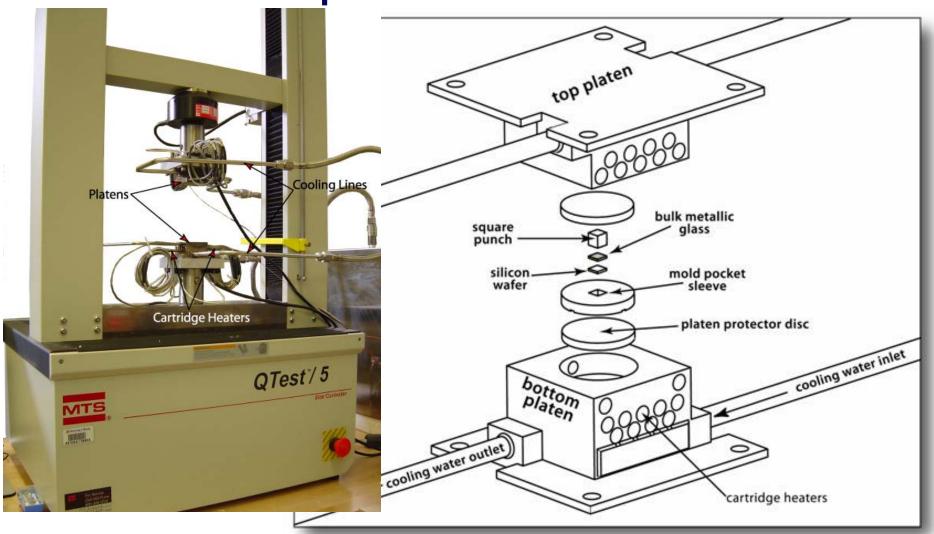






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Accomplishments and Results







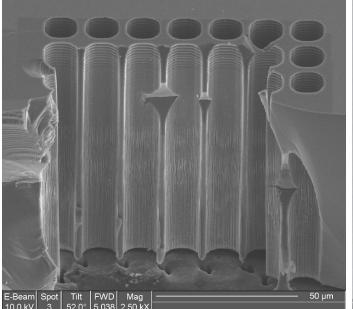


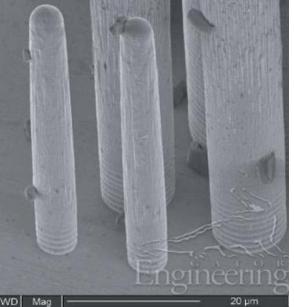
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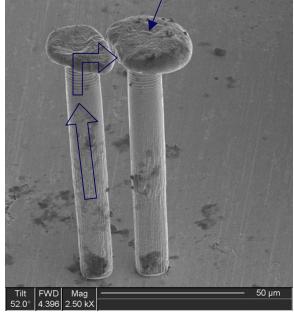
- process steps
 - 1. design mold layout in CAD
 - 2. pattern silicon wafer using DRIE (sacrificial mold)
 - 3. separate wafer into 5 mm x 5 mm molds
 - 4. insert silicon mold and bulk metallic glass into mold pocket
 - 5. heat, mold, cool (400 475 deg C, 100 to 150 MPa)

6. dissolve silicon mold in KOH bath









non line-

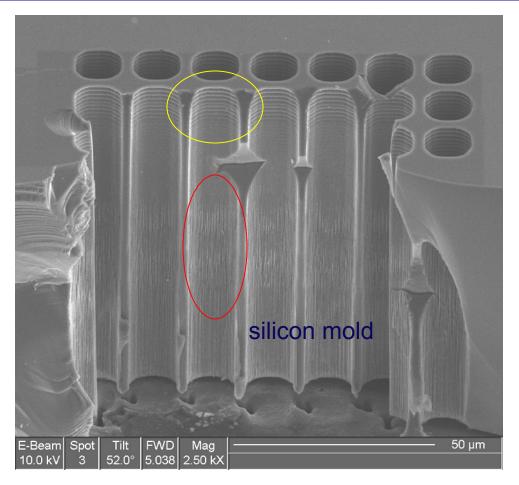
of-site flow

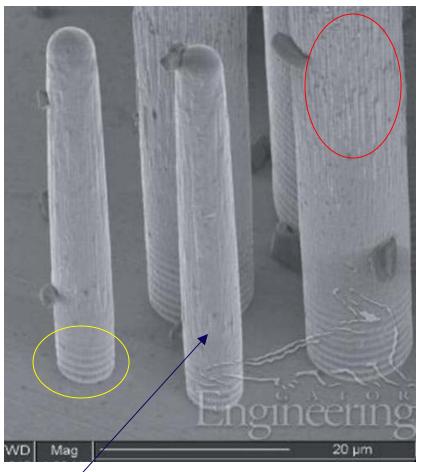






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- 5 μm dia. x 60 μm tall (12:1)
- Scallop and striation reproduction at µm level

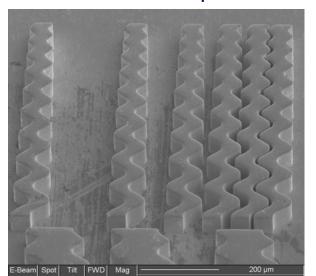


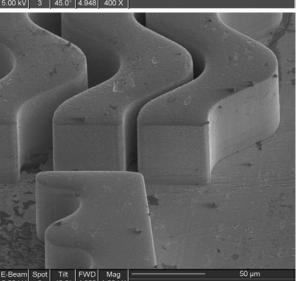




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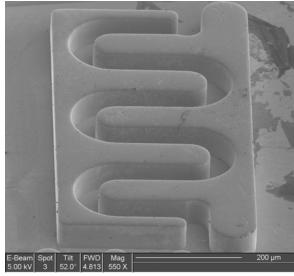
channel production

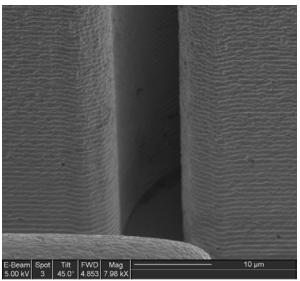


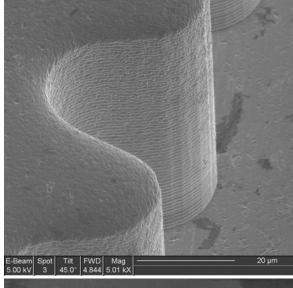


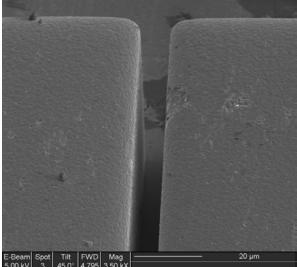


60 μm cavity depth in wafer









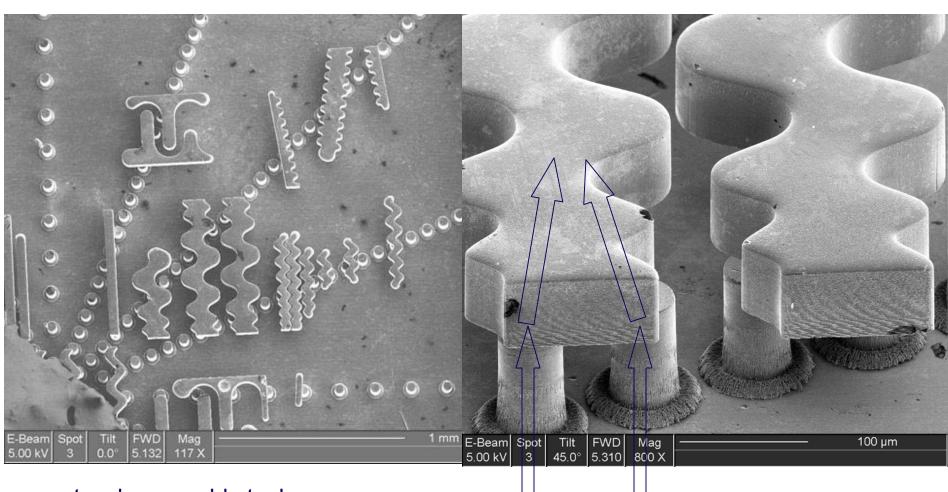
Task Title - PI - Organization







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two layer mold stack

flow through pins to fill cantilevers

metallic glass flow through two wafers

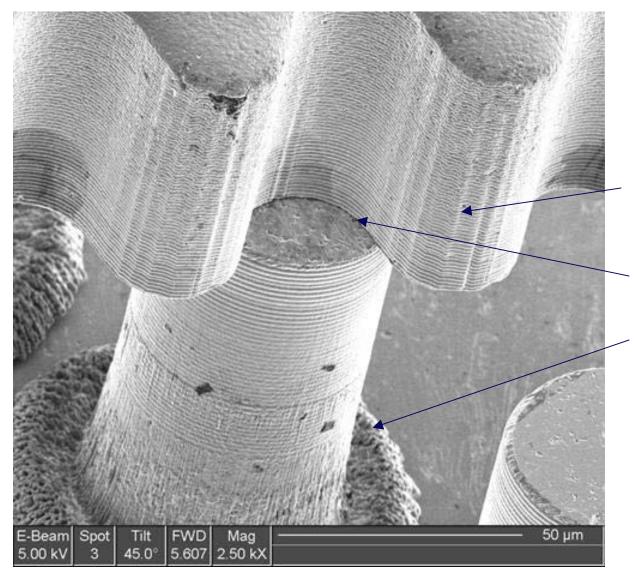
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- two layer junction
- no wafer bonding

scallop reproduction

no flash

footing from etching

Note: shrinkage normally associated with molding is not present – bulk metallic glass







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Future Plans

- process concept validated
- micro-mold polymers
- add layers
- continue high-speed machining; move to 100 μ m dia. endmills (channels for Chung)

Cooling plate with 56, 1 mm channels for Dr. Klausner